

Title (en)
DEVICE FOR ELECTROLYTIC METAL DEPOSITION AND OPERATION METHOD THEREOF

Publication
EP 0320482 B1 19920819 (FR)

Application
EP 88870180 A 19881206

Priority
BE 8701421 A 19871211

Abstract (en)
[origin: EP0320482A1] The device comprises a wall consisting of a plurality of electrically conductive members (15) separated by electrically insulating members (16). A proportion of the slots (5) for feeding electrolyte are situated in the electrically conductive members, while a proportion of the slots (6) for removing the electrolyte are situated in the electrically insulating members. At least a proportion of the electrically conductive members are connected to a terminal of a source of direct current (14), the other terminal of the source of direct current being connected to the substrate (2). The height of the electrolysis gap (11) may vary periodically. <IMAGE>

IPC 1-7
C25D 5/08

IPC 8 full level
C25D 5/08 (2006.01)

CPC (source: EP US)
C25D 5/08 (2013.01 - EP US); **C25D 5/611** (2020.08 - EP US); **C25D 5/623** (2020.08 - EP US)

Cited by
EP0520324A1; US5335681A

Designated contracting state (EPC)
AT BE DE FR GB IT LU NL

DOCDB simple family (publication)
EP 0320482 A1 19890614; EP 0320482 B1 19920819; AT E79655 T1 19920915; BE 1001295 A6 19890919; DE 3873892 D1 19920924

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